

High-k metal oxide thin film by chemical spray pyrolysis : from optimization of material properties to application in thin film transistor = Metallioksiidi õhukesed kiled keemilise pihustuspürolüsi meetodil : materjali omaduste optimeerimine ja rakendamine õhukese kilelistes transistorides

Oluwabi, Abayomi Titilope 2020 <https://digikogu.taltech.ee/et/item/4b6d9af7-74d2-40ac-9c12-335d2f608474>

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